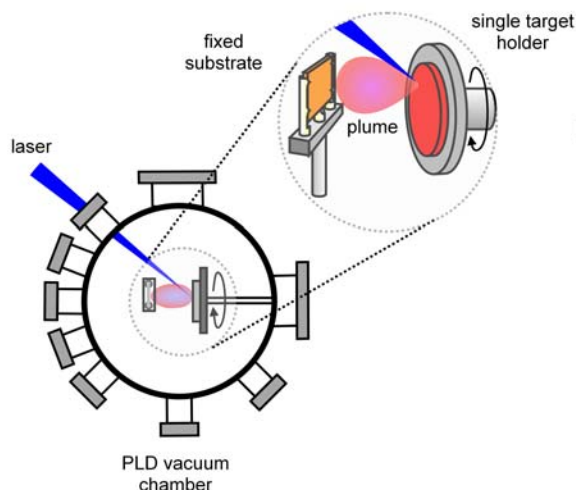


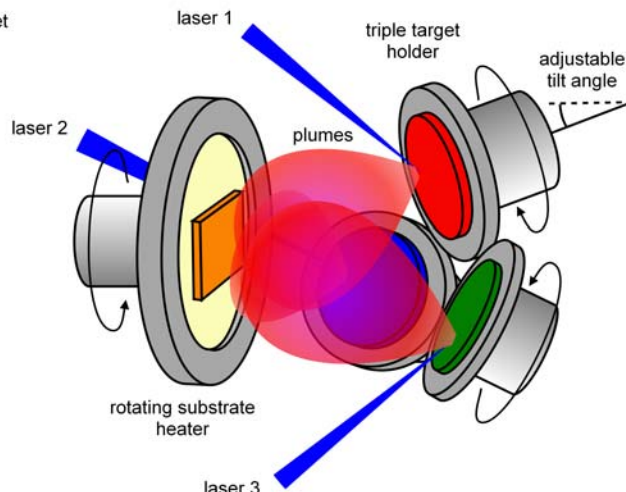
**Invited talk at Tyndall National Institute, "Lee Maltings", Prospect Row, Cork, Ireland, April 3<sup>rd</sup>, 2007.**

**Pulsed laser deposition for growth of high quality epitaxial garnet films for low threshold waveguide lasers.**

**(a) Conventional PLD**



**(b) MULTIPLE PLD**



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**Abstract:**

Pulsed laser deposition (PLD) is a mature technique capable of producing extremely high quality epitaxial single crystalline films. We have grown Nd:doped garnet films of GGG ( $\text{Gd}_3\text{Ga}_5\text{O}_{12}$ ) on YAG substrates, with thicknesses from a few  $\mu\text{m}$  to more than 100  $\mu\text{m}$  for both single mode and multimode waveguide applications. Our lowest losses for single-mode guides are less than  $0.1\text{dB cm}^{-1}$ , and the resulting structures yield excellent waveguide lasing.

The talk will summarise our progress using conventional (single beam) PLD in thin-film and waveguide growth, using both nanosecond and femtosecond lasers, and also introduce our new directions in tri-beam PLD (three targets, three lasers) for growth of some interesting, complex and perhaps impossible structures, such as Gaussian doping, internal voids and even helically doped structures.